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# FACULTY OF ENGINEERING AND TECHNOLOGY MEC-022 Lecture - 09

## **Channel-Length Modulation**



- On the previous *iv*-characteristics, the saturation part was horizontal (the current was constant, as v<sub>DS</sub> increases). However, it's not exactly so.
- As v<sub>DS</sub> increases above v<sub>DSAT</sub>, length of depleted channel beyond pinch-off point, ΔL, increases and actual L decreases.
- Since *L* is in denominator of the current expression, it compensate slightly the general increase of resistivity, which normally makes the curve flat.
- As a result, *i<sub>D</sub>* increases slightly with *v<sub>DS</sub>* instead of being constant and we can rewrite equation in the form:



where  $\lambda$  is the channel length modulation parameter, depends on manufacturing and *L*.

### Output and Transfer Characteristics of MOSFETS

- A MOSFET has one output variable the drain-source current , that depends on two input variables drain-source voltage and gate-source voltage (V<sub>GS</sub> is usually is a control variable).
- Two types of iv-curves are used to describe a MOSFET device fully: output (drain) curve (DS current vs. DS voltage for a fixed GS voltage) (the earlier considered characteristics were drain curves)



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- Two types of iv-curves are used to describe a MOSFET device fully: output (drain) curve (DS current vs. DS voltage for a fixed GS voltage) (the earlier considered characteristics were drain curves) transfer curve (DS current vs. GS voltage for a fixed DS voltage, *f.i. sat.*)





So far it was assumed that the source-bulk voltage  $v_{SB}$ , is zero, which means that a MOSFET is a three terminal device. Quite often  $v_{SB}$ , especially in ICs is not zero.



- Non-zero  $v_{SB}$  changes threshold voltage.
- This is called substrate sensitivity and is modeled by

$$V_{TN} = V_{TO} + \gamma \left( \sqrt{v_{SB} + 2\phi_F} - \sqrt{2\phi_F} \right)$$

where

- $V_{TO}$  zero substrate bias for  $V_{TN}$  (V)
- $\gamma \text{body-effect parameter } ( ) \mu, \text{ determines}$ the intensity of the body effect
- $2\Phi_{\rm F}$  surface potential parameter (V), typically 0.6V.

### NMOS Summary (output characteristics)



## PMOS Transistors Structure (Enhancement-Mode)



*p*-type source and drain regions in *n*-type substrate.



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